

# A copper(II) oxide – tin dioxide heterojunction sensor for the detection of hydrogen sulfide

*Stefan Lehmann*<sup>1</sup>, *Marie-Luise Bauersfeld*<sup>2</sup>, *Jürgen Wöllenstein*<sup>2,3</sup>

<sup>1</sup> *Dräger Safety GmbH & Co KGaA, Revalstrasse, Lübeck, Germany,*

<sup>2</sup> *Fraunhofer IPM, Heidenhofstrasse, Freiburg, Germany*

<sup>3</sup> *Laboratory for Gas Sensors, IMTEK, University of Freiburg, Germany*

*Stefan.Lehmann@draeger.com*

## Abstract

We present a novel sensor concept for highly sensitive detection of hydrogen sulfide (H<sub>2</sub>S) using the heterojunction copper(II) oxide - tin dioxide. Unlike other approaches, we use a thin film stack of the semiconductors where the CuO completely covers the SnO<sub>2</sub>. The basic idea hereby is to prevent the SnO<sub>2</sub>-layer from the contact of reactive gases in order to reduce cross sensitivities. The films were prepared by reactive electron beam evaporation of copper and tin oxide. Structural and morphological analyses of the films were carried out. The sensitivity, selectivity and stability of the device has been evaluated using several reactive gases including long term tests. The sensor is extremely sensitive to traces of H<sub>2</sub>S. A slight cross sensitivity to NO<sub>2</sub> is observed.

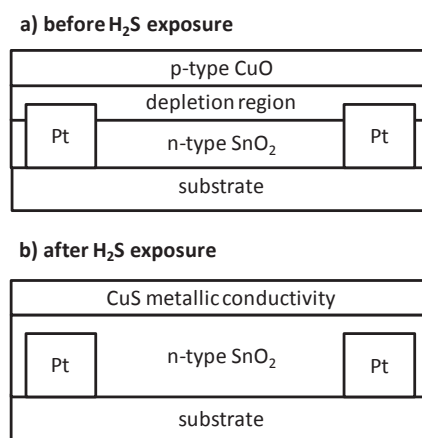
**Key words:** gas sensing, hydrogen sulfide, copper(II) oxide, tin dioxide, pn-junction, selectivity

## Introduction

Hydrogen sulfide (H<sub>2</sub>S) is a highly toxic and corrosive gas whose odor is usually associated with rotten eggs. In the harsh environment of oil- / gas extraction, gas warning systems are necessary for employees safety. Typical concentration levels in applications for H<sub>2</sub>S sensors range from sub-ppm to thousands of ppm. A review of the various detection methods can be found in [1]. However, metal oxide gas sensors, fabricated on silicon substrates provide compatibility with common microelectronics and MEMS systems and enable low cost fabrication. Copper(II) oxide (CuO) is well known for its highly specific interaction with hydrogen sulfide, namely the formation of sulfidic structures [2]:  $\text{CuO} + \text{H}_2\text{S} \rightarrow \text{CuS} + \text{H}_2\text{O}$ .

Beside research activities to use “pure” CuO for H<sub>2</sub>S sensors [3], various works on copper and copper oxide as dopant or additive material in tin dioxide (SnO<sub>2</sub>) sensors were published. The idea to markedly enhanced response of SnO<sub>2</sub> sensing elements towards H<sub>2</sub>S exposure when doped with 5 w% CuO was published in 1992 [2]. Several experimental and theoretical studies followed. The term of so-called heterojunction sensor was assigned to the CuO:SnO<sub>2</sub> sensing effect. This originates from the effect that n-SnO<sub>2</sub> and p-CuO form pn-

junctions and a corresponding depletion region. When exposed towards H<sub>2</sub>S, CuO gets converted to CuS and the space charge region consequently collapses, resulting in a drastic increase of conductivity. Beside simple mixing of both materials in a thick film, SnO<sub>2</sub> films with CuO islands on top, heterostructures of CuO-SnO<sub>2</sub> thin films [4], CuO doped SnO<sub>2</sub> thin films and CuO modified SnO<sub>2</sub> nanoribbons [5] have been reported. We present an approach featuring a stack of a CuO and a highly densified SnO<sub>2</sub> thin film (fig 1).



*Fig. 1. a) “Stack sensor” approach: P-type CuO and highly dense n-type SnO<sub>2</sub> thin film form a pn-junction. b) Due to H<sub>2</sub>S exposure the CuO is converted to CuS and the depletion region collapses.*

## Experimental

A microscope picture of the sensor chip fabricated on silicon substrate is shown in fig 2. An oxidized silicon wafer is used as substrate. A 200 nm thick Pt film with a 25 nm Ta adhesion layer has been deposited and patterned to act as electrodes, heater and temperature sensor. The metal oxides are deposited and patterned by use of the lift-off method. The SnO<sub>2</sub> films, of 60 nm thickness, and the CuO films (20 nm thick) were deposited by reactive e-beam evaporation of SnO or copper and a subsequent oxidation. The CuO:SnO<sub>2</sub> stack was stabilized by annealing at 700 °C for one hour in air.

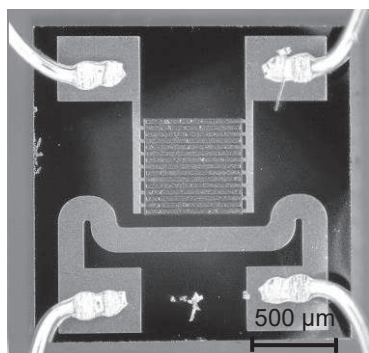


Fig.2. Microscope picture of the fabricated sensor chip (2x2 mm<sup>2</sup>). Due to the high thermal conductivity of the silicon substrate, the resistive heating via a Pt:Ta heater reveals a homogeneous temperature distribution along the gas sensitive layer. Interdigitated Pt:Ta electrodes with a spacing of 10 μm in between them provide the interface to determine the electrical conductivity of the CuO:SnO<sub>2</sub>-layer.

The morphological characteristics of all fabricated layers were investigated with X-ray analysis and scanning electron microscopy. The processed wafers were diced. The chips are mounted into TO5-housings and are connected using a 35 μm thick gold wire by ultrasonic bonding. For a better thermal isolation of the chip against the metal housing a glass spacer is used. Each mounted sensor was preheated in air for 48 h at 300 °C before the gas measurements. The response of sensors to different concentrations of H<sub>2</sub>S, NO<sub>2</sub>, CO and ethanol was measured at a number of working temperatures. Fig. 3 shows the typical response of such sensors to these gases in synthetic air (50 % r.h., 25 °C). The working temperature was 290 °C. Significant changes in resistance are observed only for sensors exposed to H<sub>2</sub>S and NO<sub>2</sub>. The responses time (t<sub>90</sub>) is 15 sec for 2 ppm H<sub>2</sub>S with a detection limit of 0.2 ppm and a recovery time (t<sub>10</sub>) of 7 min. The NO<sub>2</sub>-response is two to three powers of ten smaller as the sensitivity to H<sub>2</sub>S. The response to H<sub>2</sub>S concentrations in the

lower ppm range is extremely high due to the reversible transition of CuO to CuS. The NO<sub>2</sub> reaction is the “normal” charge carrier exchange of oxidizing gases with p-type semiconducting metal oxide. Long term tests of the sensors over month in the gas lab and at the rooftop of the Dräger building in Lübeck reveals a slight drift of the resistance in air and the sensitivity to lower values.

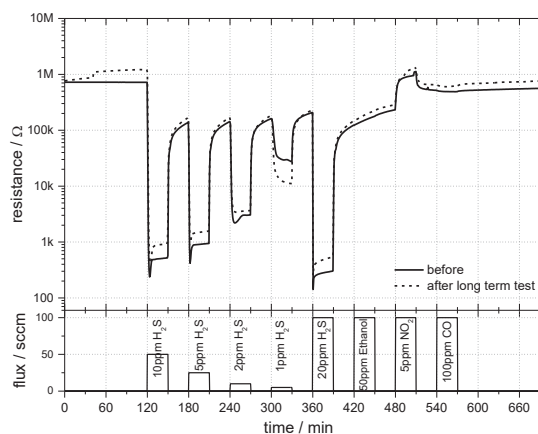


Fig.3. Gas response of CuO:SnO<sub>2</sub> heterojunction gas sensors at a working temperature of 290 °C exposed to different test gases in humid synthetic air (50 % r.h. @ 23 °C). Diagrammed is the gas response towards the same test gases before and after a long term test of 88 days. The lower diagram shows the test gas flow during the experiments.

## Conclusion

Our research revealed that a stacked SnO<sub>2</sub> CuO heterojunction sensor shows a high sensitivity to H<sub>2</sub>S. An insignificant NO<sub>2</sub> and O<sub>3</sub>-response is observed. No cross sensitivity to traces of SO<sub>2</sub>, H<sub>2</sub>, NH<sub>3</sub>, CH<sub>4</sub> are measured. Humidity (20 to 80 % r.h. @ RT) has no significant influence on the sensor response.

## References

- [1] S.K. Pandey et al., A review of sensor-based methods for monitoring hydrogen sulfide, *Trend. Anal. Chem.* 32 (2012) 87-99.
- [2] J. Tamaki et al., CuO-SnO<sub>2</sub> element for highly sensitive and selective detection of H<sub>2</sub>S, *Sens. Actuators B: Chem.* 8 (1992) 197-203.
- [3] J. Kneer et al., Specific, trace gas induced phase transition, in copper(II) oxide for highly selective gas sensing, *Applied Physics Letters*, 105:073509, 2014.
- [4] M. Verma et al., Comparison of H<sub>2</sub>S sensing response of hetero-structure sensor (CuO-SnO<sub>2</sub>) prepared by rf sputtering and pulsed laser deposition, *Thin Solid Films* 518 (2010) 181-182.
- [5] X. Kong et al., High sensitivity of CuO modified SnO<sub>2</sub> nanoribbons to H<sub>2</sub>S at room temperature, *Sens. Actuators B: Chem.* 105 (2005) 449-453.